

**INFORMATION DISCLOSURE CITATION**  
*(Use several sheets if necessary)*

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Docket Number (Optional) <b>NEC A433</b>	Application Number
Applicant(s) <b>TOUNAI</b>	
Filing Date <b>March 31, 2004</b>	Group Art Unit

## **U.S. PATENT DOCUMENTS**

## **FOREIGN PATENT DOCUMENTS**

REF	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
						YES	NO
/E.P./	2000-214577	04.08.2000	JAPAN (w/Abstract)	G03F	1/08		✓
/E.P./	11-338904	10.12.1999	JAPAN (w/Abstract)	G06F	17/50		✓
/E.P./	11-096200	09.04.1999	JAPAN (w/Abstract)	G06F	17/50		✓
/E.P./	2000-294650	20.10.2000	JAPAN (w/Abstract)	H01L	21/82		✓

**OTHER DOCUMENTS** (*Including Author, Title, Date, Pertinent Pages, Etc.*)


**EXAMINER**

/Edward Park/

**DATE CONSIDERED**

06/21/2007

**EXAMINER:** Initial if citation considered, whether or not citation is in conformance with MPEP Section 609; Draw line through citation if not in conformance and no considered. Include copy of this form with next communication to applicant.